Fundamentals of Nanotransistors L1.3 Quiz <u>ANSWERS</u>

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Lecture 1.3: MOSFET Device Metrics

- 1) Which of the following describes the subthreshold swing of a MOSFET?
 - a) The increase in <u>drain voltage</u> needed to increase the <u>drain current</u> by a factor of 10 at a fixed gate voltage.
 - b) The increase in gate voltage needed to increase the drain current by a factor of 10 at a fixed drain voltage.
 - c) The difference in <u>gate voltage</u> divided by the difference in <u>drain voltage</u> at a constant current in the subthreshold region.
 - d) The difference in <u>drain voltage</u> divided by the difference in <u>gate voltage</u> at a constant current in the subthreshold region.
 - e) The change in <u>drain voltage</u> divided by the change in <u>drain current</u> in the saturation region.
- 2) Which of the following describes the DIBL of a MOSFET?
 - a) The increase in <u>drain voltage</u> needed to increase the <u>drain current</u> by a factor of 10 at a fixed gate voltage.
 - b) The increase in gate voltage needed to increase the drain current by a factor of 10 at a fixed drain voltage.
 - c) The difference in <u>gate voltage</u> divided by the difference in <u>drain voltage</u> at a constant current in the subthreshold region.
 - d) The difference in <u>drain voltage</u> divided by the difference in <u>gate voltage</u> at a constant current in the subthreshold region.
 - e) The change in <u>drain voltage</u> divided by the change in <u>drain current</u> in the saturation region.
- 3) Which of the following expressions describes the transconductance of a MOSFET?

$$\begin{array}{l} \text{a)} & \left\| I_{DS} / \left\| V_{DS} \right\|_{V_{GS}} \\ \text{b)} & \left\| I_{DS} / \left\| V_{GS} \right\|_{V_{DS}} \\ \text{c)} & \left\| V_{DS} / \left\| I_{DS} \right\|_{V_{GS}} \\ \text{d)} & \left\| V_{GS} / \left\| I_{DS} \right\|_{V_{DS}} \\ \text{e)} & \left\| V_{DS} / \left\| V_{GS} \right\|_{I_{DS}} \\ \end{array} \right\|_{L_{DS}}$$